In re Appln. of INOUE et al. Application No. Unassigned

## ABSTRACT AMENDMENTS

Replace the Abstract with:

A high power semiconductor device in which there are a plurality of including gate electrodes also includes; an active region of an approximately rectangular shape which is formed, located on a semiconductor substrate; a drain electrode which is formed located on the active region; and a first and a second source electrodes which are disposed on the both opposite sides to the drain electrode in such a manner so that the first and the second source electrodes face each other across at least some of the gate electrodes. The directions of currents carried by the first and the second source electrodes are opposite to each other.